## AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the application:

## **LISTING OF CLAIMS:**

1. (original): A Group III nitride semiconductor light-emitting device comprising:

a stacked structure formed on a crystal substrate to be removed from it and including two Group III nitride semiconductor layers having different electric conductive types and a lightemitting layer which is stacked between the two Group III nitride semiconductor layers and which comprises a Group III nitride semiconductor; and

a plate body made of material different from that of the crystal substrate and formed on a surface of an uppermost layer which is opposite from the crystal substrate that is removed from the stacked structure.

- 2. (original): The Group III nitride semiconductor light-emitting device according to claim 1, wherein the plate body is made of conductive material.
- 3. (currently amended): The Group III nitride semiconductor light-emitting device according to claim 1-or 2, wherein the crystal substrate is removed from the stacked structure by irradiating laser beams onto a junction interface region between the stacked structure and the crystal substrate.

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Preliminary Amendment

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4. (currently amended): The Group III nitride semiconductor light-emitting device according to

claim 1 any one of claims 1 to 3, further comprising an ohmic electrode provided on the plate

body.

5. (currently amended): The Group III nitride semiconductor light-emitting device according to

claim 1 any one of claims 1 to 4, wherein the plate body is formed on the surface of the

uppermost layer through a metal layer.

6. (original): The Group III nitride semiconductor light-emitting device according to claim 5,

wherein the metal layer comprises eutectic metal film.

7. (currently amended): The Group III nitride semiconductor light-emitting device according to

claim 1 any one of claims 1 to 6, further comprising a metal reflection film for reflecting light

from the light-emitting layer provided between the plate body and the surface of the uppermost

layer.

8. (currently amended): The Group III nitride semiconductor light-emitting device according to

claim 1 any one of claims 1 to 7, wherein the crystal substrate is a sapphire substrate having a

(0001) face on which the stacked structure is formed, and the plate body is a conductive (001) -Si

monocrystal.

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9. (original): The Group III nitride semiconductor light-emitting device according to claim 8, wherein the plate body has a <110> crystal orientation that is in parallel to a [1.1.-2.0) crystal orientation of the (0001)-sapphire substrate.

10. (original): A method of producing a Group III nitride semiconductor light-emitting device comprising the steps of:

forming on a crystal substrate to be removed a stacked structure including two Group III nitride semiconductor layers having different electric conductive types and a light-emitting layer which is stacked between the two Group III nitride semiconductor layers and which comprises a Group III nitride semiconductor;

forming a plate body made of material different from that of the crystal substrate on a surface of an uppermost layer which is opposite from the crystal substrate; and removing the crystal substrate.

11. (currently amended): An LED lamp having the Group III nitride semiconductor lightemitting device according to <u>claim 1 any one of claims 1 to 9</u>.